Supplementary material

Modulation of electronic band structure of silicene by polar two-

dimensional substrates

Table.S1. the exfoliation energy (E_{exf}) and band gap of Si/Janus

Species .	Band gap(eV)		$E_{exf}(meV/Å^2)$.		
Ga ₂ SSe(S/Se)	0.1360/0.1680		15/19 .		
$In_2SSe(S/Se)$	0.1437/0.1379		16/16 .		
$GaInS_2(Ga/In)$.	0.1539/0.1790		15/17。		
Structure	C ₁₁	C ₁₂	C ₆₆		
Structure	C ₁₁	C ₁₂	C ₆₆		
Ga ₂ SSe/S	133.22	35.79	1.07		
Ga ₂ SSe/Se	132.57	35.48	1.25		
In ₂ SSe/S	121.93	37.40	1.31		
In ₂ SSe/Se	119.57	37.99	2.83		
GaInS ₂ /Ga	126.46	36.59	1.19		
GaInS ₂ /In	125.70	36.53	2.11		

-390 -390 (a) (b) -395 -395 E(eV/supercell) E(eV/supercell) -400 -400 -405 -405 -410 -410 ^{3ps} Time 0ps 6ps 0ps Time 6ps -365 -370 (d) (c) -370 -375 E(eV/supercell) E(eV/supercell) -375 -380 -380 -385 -385 -390 ^{3ps} Time 6ps 0ps ^{3ps} Time 6ps 0ps



Figure.S1. Energy fluctuations of (a) Si/Ga₂SSe-S, (b) Si/Ga₂SSe-Se, (c) Si/In₂SSe-S, (d) Si/In₂SSe-Se, (e) Si/GaInS₂-Ga, (f) Si/GaInS₂-In during MD simulations at 300K.



Figure.S2. Phonon spectrum of (a) Si/Ga₂SSe-S, (b) Si/Ga₂SSe-Se, (c) Si/In₂SSe-S, (d) Si/In₂SSe-Se, (e) Si/GaInS₂-Ga, (f) Si/GaInS₂-In.



Figure.S3. Band structures near the Fermi levels of (a) the Si/In₂SSe heterojunction with Si/S interface and (b) the Si/In₂SSe heterojunction with Si/Se interface under different electric fields E_z



Figure.S4. Band structures near the Fermi levels of (a) the Si/GaInS₂ heterojunction with Si/Ga interface and (b) the Si/GaInS₂ heterojunction with Si/In interface under different electric fields E_z .